

Heta-Elisa Nieminen

List of Publications by Year in descending order

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6
papers

79
citations

1684188
5
h-index

1872680
6
g-index

6
all docs

6
docs citations

6
times ranked

176
citing authors

#	ARTICLE	IF	CITATIONS
1	Reaction mechanism studies on atomic layer deposition process of AlF ₃ . Journal of Vacuum Science and Technology A: Vacuum, Surfaces and Films, 2022, 40, .	2.1	2
2	Ambient pressure x-ray photoelectron spectroscopy setup for synchrotron-based in situ and operando atomic layer deposition research. Review of Scientific Instruments, 2022, 93, 013905.	1.3	9
3	Synchronizing gas injections and time-resolved data acquisition for perturbation-enhanced APXPS experiments. Review of Scientific Instruments, 2021, 92, 044101.	1.3	11
4	<i>In Situ</i> Reaction Mechanism Study on Atomic Layer Deposition of Intermetallic Co ₃ Sn ₂ Thin Films. Chemistry of Materials, 2020, 32, 8120-8128.	6.7	6
5	Atomic Layer Deposition of Photoconductive Cu ₂ O Thin Films. ACS Omega, 2019, 4, 11205-11214.	3.5	40
6	Intercalation of Lithium Ions from Gaseous Precursors into δ -MnO ₂ Thin Films Deposited by Atomic Layer Deposition. Journal of Physical Chemistry C, 2019, 123, 15802-15814.	3.1	11